

**Lecture 1**  
**Modeling and simulation for the growth of**  
**thin films**

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# Outline

- Epitaxial Growth
  - molecular beam epitaxy (MBE)
  - Step edges and islands
- Solid-on-Solid using kinetic Monte Carlo
  - Atomistic, stochastic
- Island dynamics model
  - Continuum in lateral directions/atomistic in growth direction
  - Level set implementation
  - Kinetic step edge model
- Conclusions

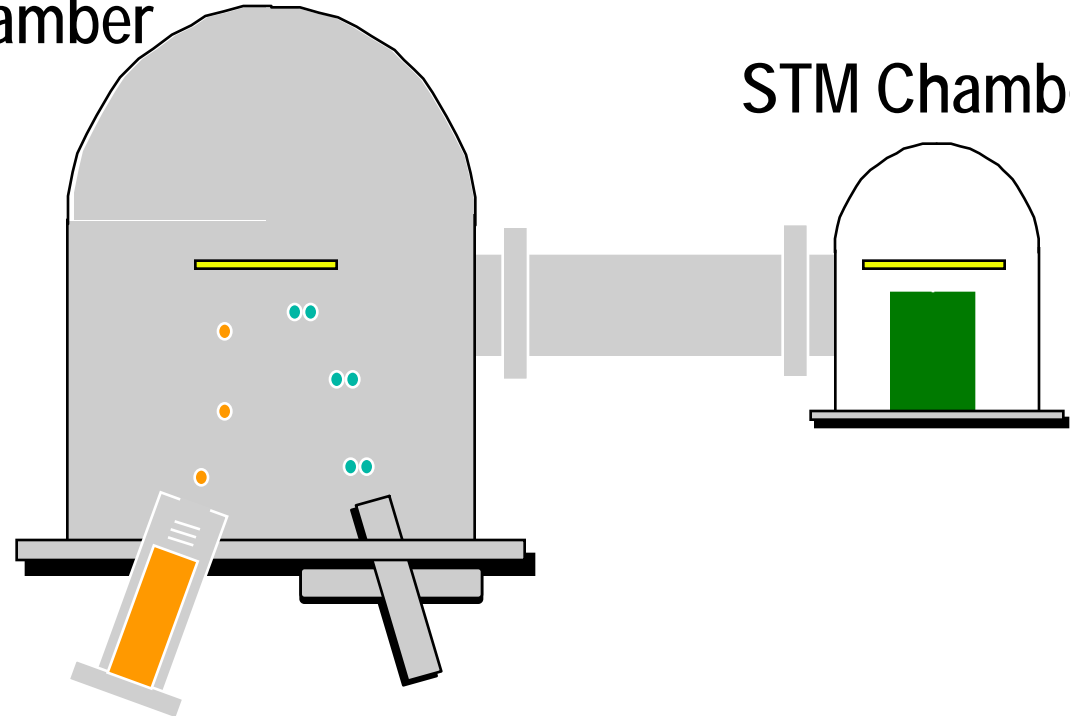
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# Molecular Beam Epitaxy (MBE) Growth and Analysis Facility

MBE Chamber

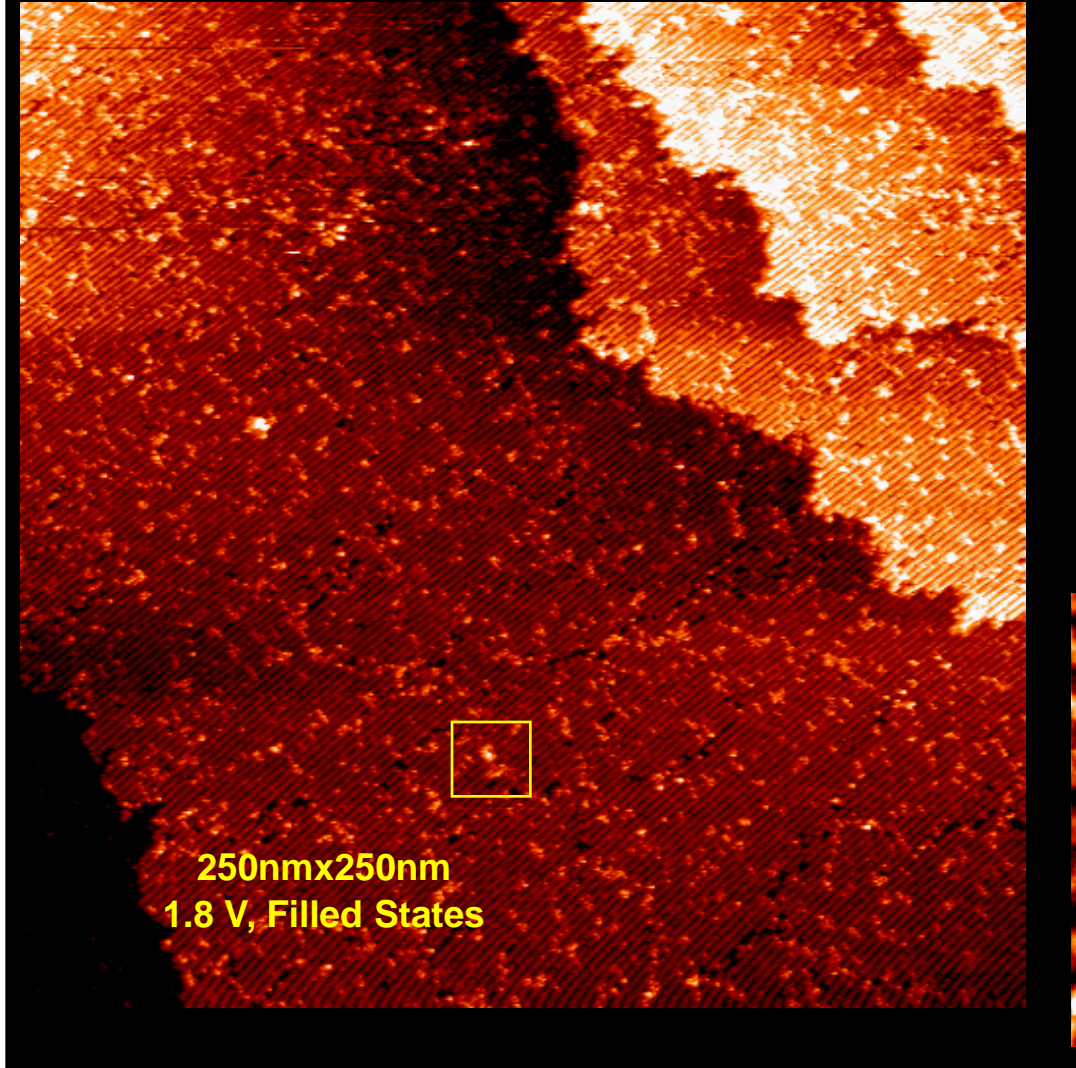
STM Chamber



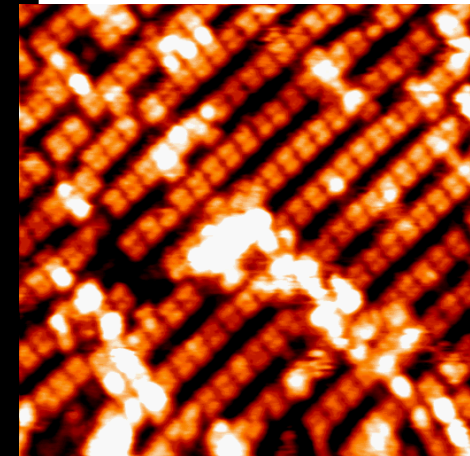
Effusion Cells

# STM Image of InAs

HRL whole-wafer STM  
surface quenched from 450° C, "low As"



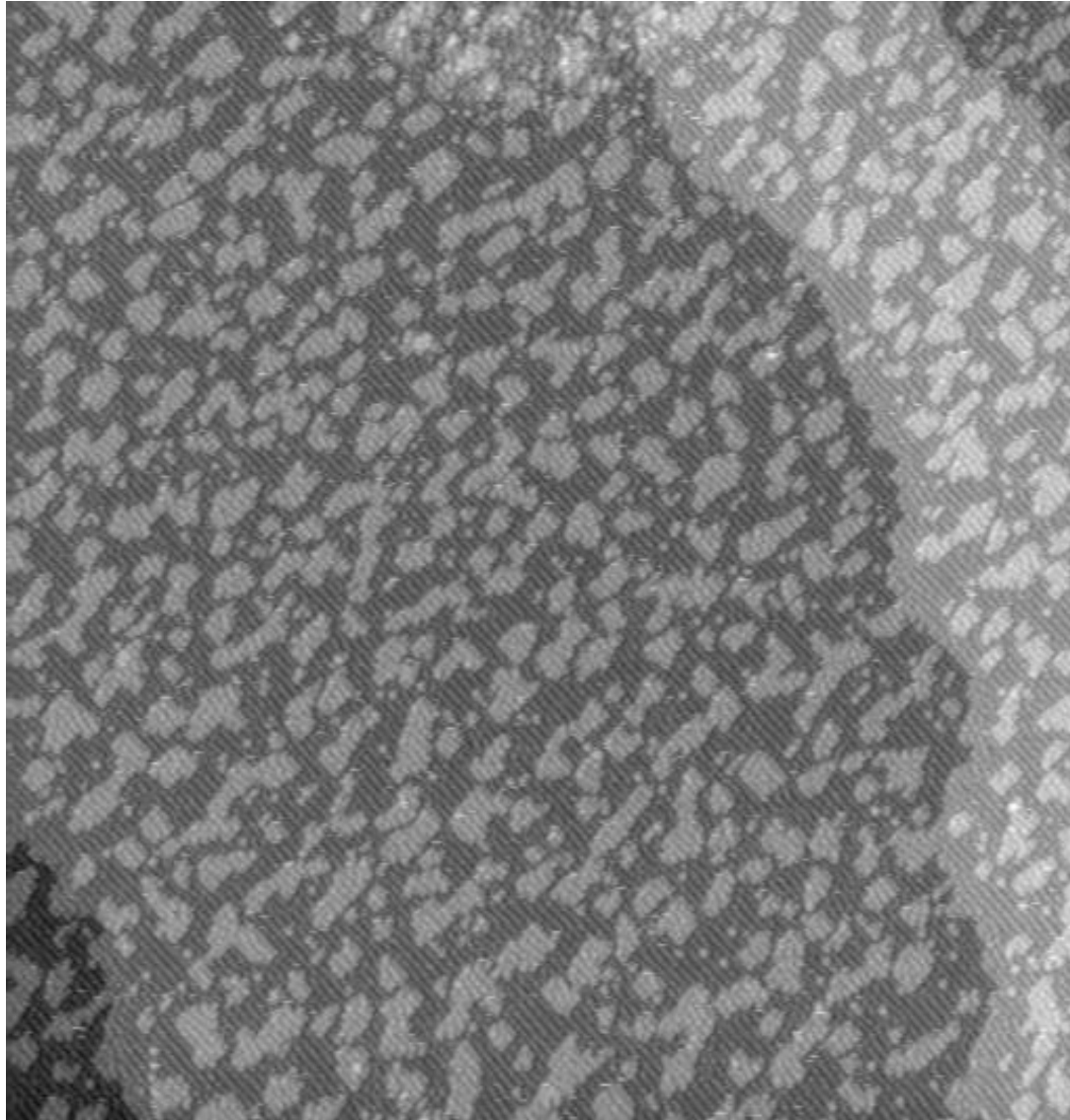
20nmx20nm



250nmx250nm  
1.8 V, Filled States

Barvosa-Carter,  
Owen, Zinck  
(HRL Labs)

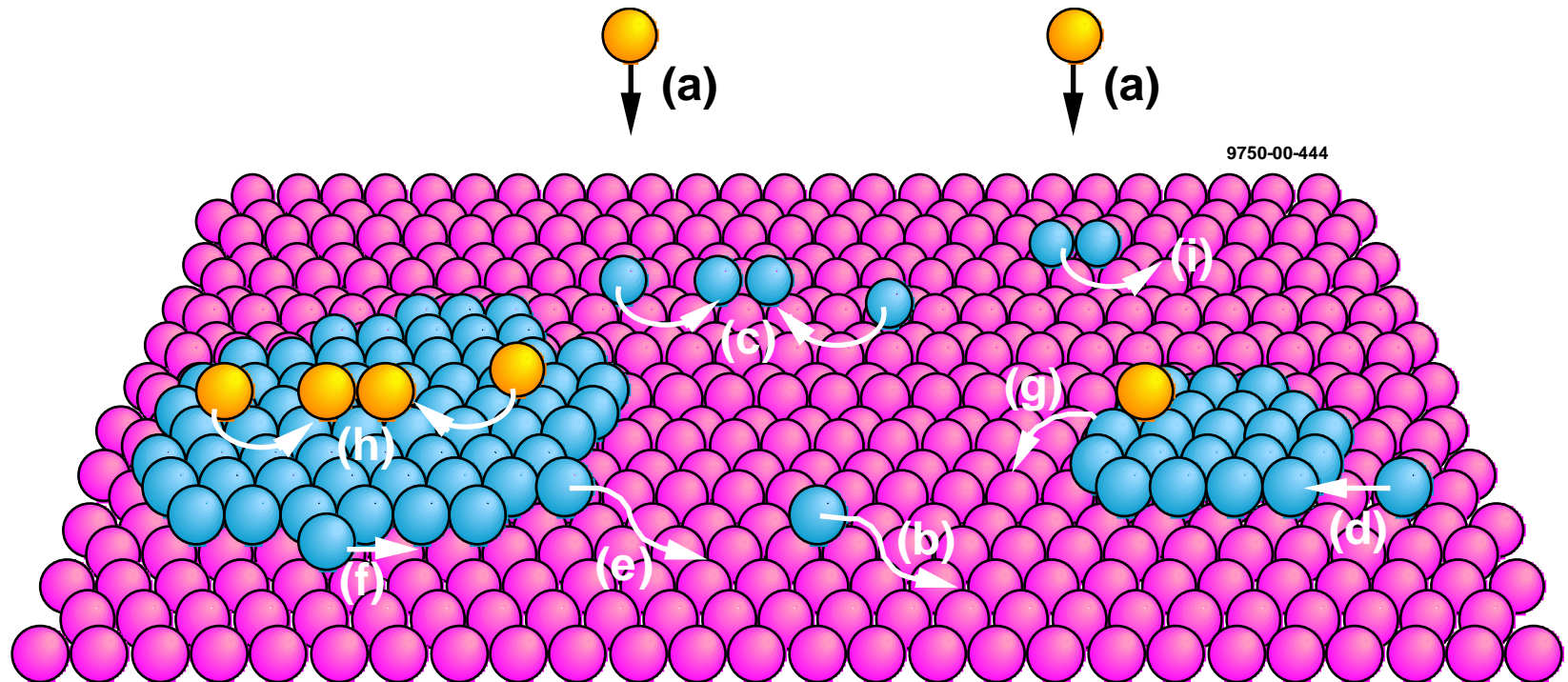
# AlSb Growth by MBE



Barvosa-Carter and Whitman, NRL

Sapporo 2010

# Basic Processes in Epitaxial Growth



- |                |                                  |
|----------------|----------------------------------|
| (a) deposition | (f) edge diffusion               |
| (b) diffusion  | (g) diffusion down step          |
| (c) nucleation | (h) nucleation on top of islands |
| (d) attachment | (i) dimer diffusion              |
| (e) detachment |                                  |

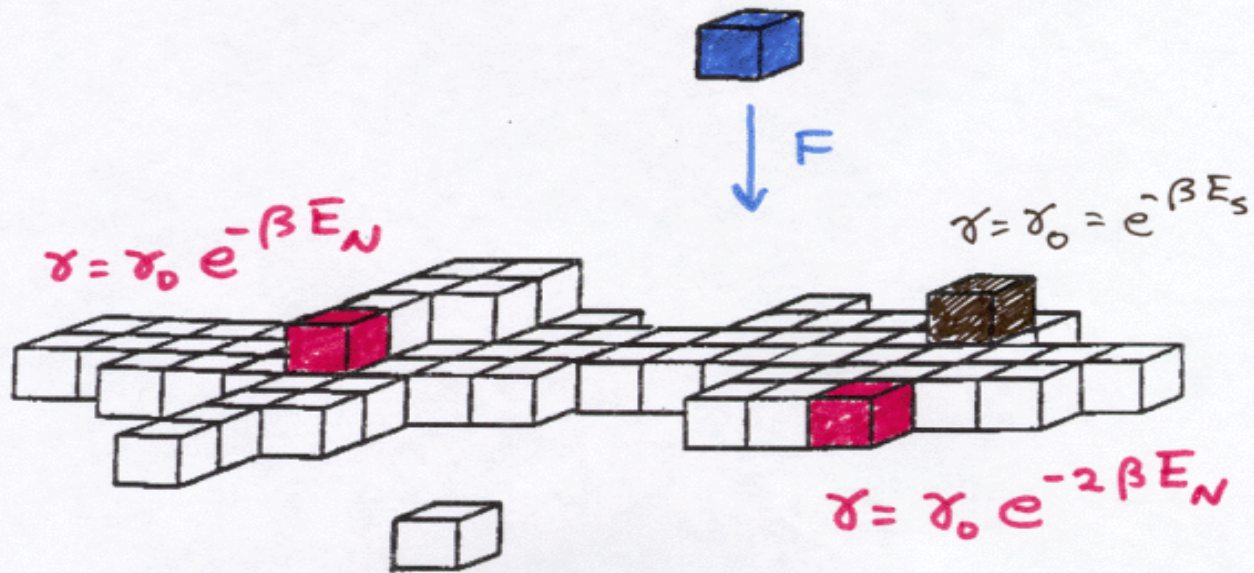
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# Solid-on-Solid Model

- Interacting particle system
  - Stack of particles above each lattice point
- Particles hop to neighboring points
  - random hopping times
  - Arrhenius hopping rate  $D = D_0 \exp(-E/T)$ ,
  - $E$  = energy barrier, depends on nearest neighbors
- Deposition of new particles
  - random position
  - arrival frequency from deposition rate
- Simulation using kinetic Monte Carlo method
  - Gilmer & Weeks (1979), Smilauer & Vvedensky, ...

# Pair-bond solid-on-solid model

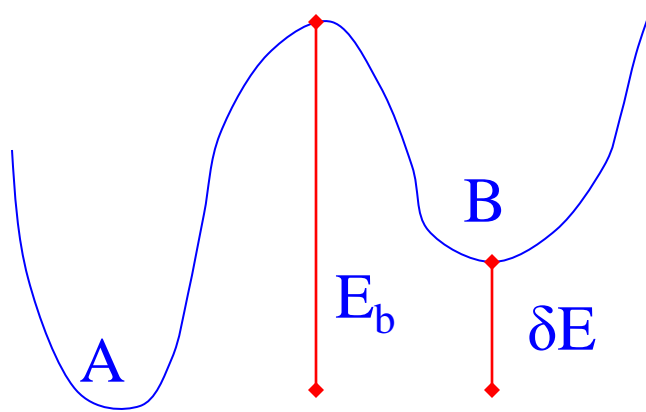


$E_s$  : Substrate Bond Energy

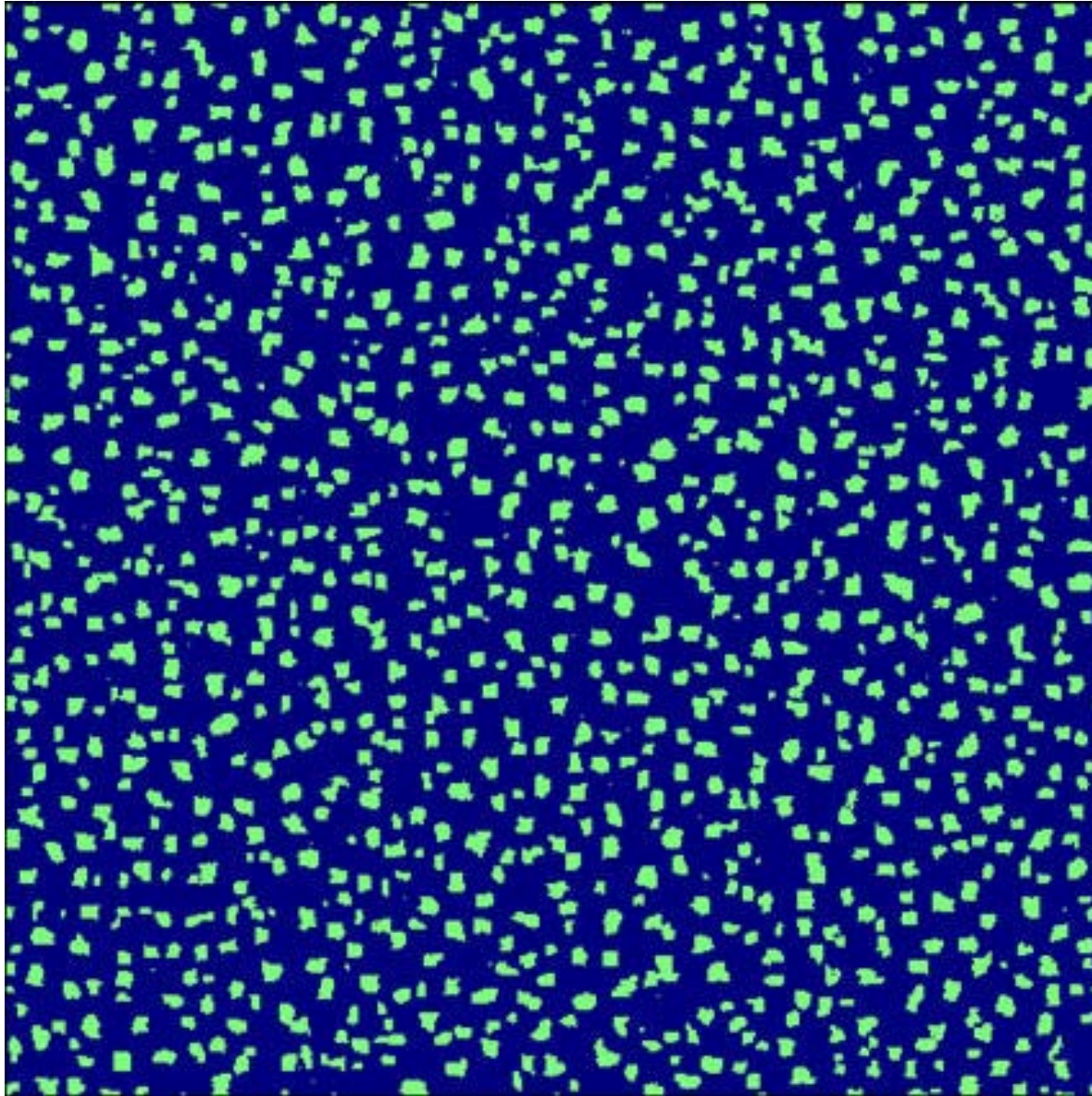
$E_N$  : Nearest Neighbor Bond Energy

# Kinetic Monte Carlo

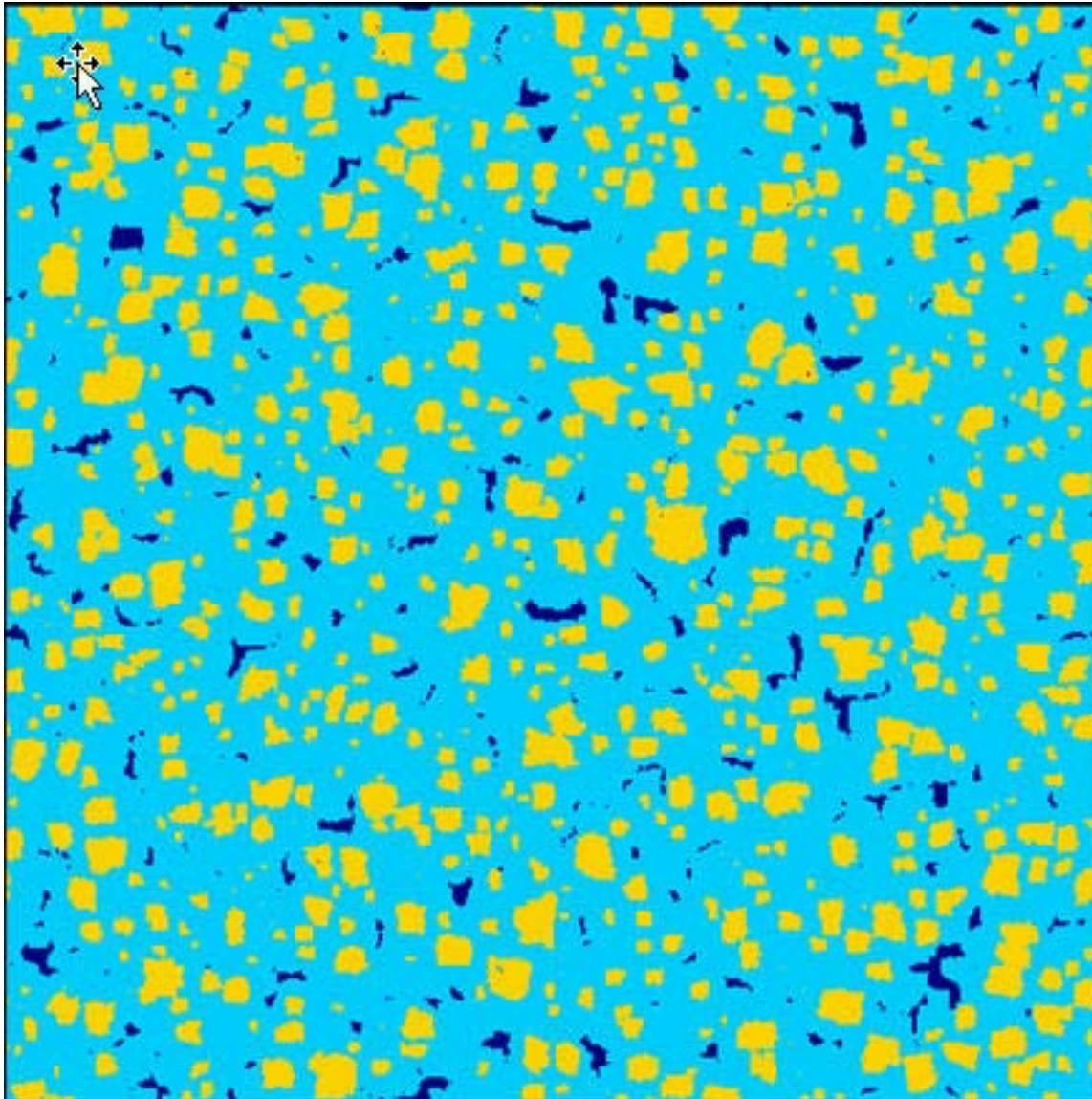
- Random hopping from site  $A \rightarrow B$
- hopping rate  $D_0 \exp(-E/T)$ ,
  - $E = E_b =$  energy barrier between sites
  - not  $\delta E =$  energy difference between sites
- Transition state theory



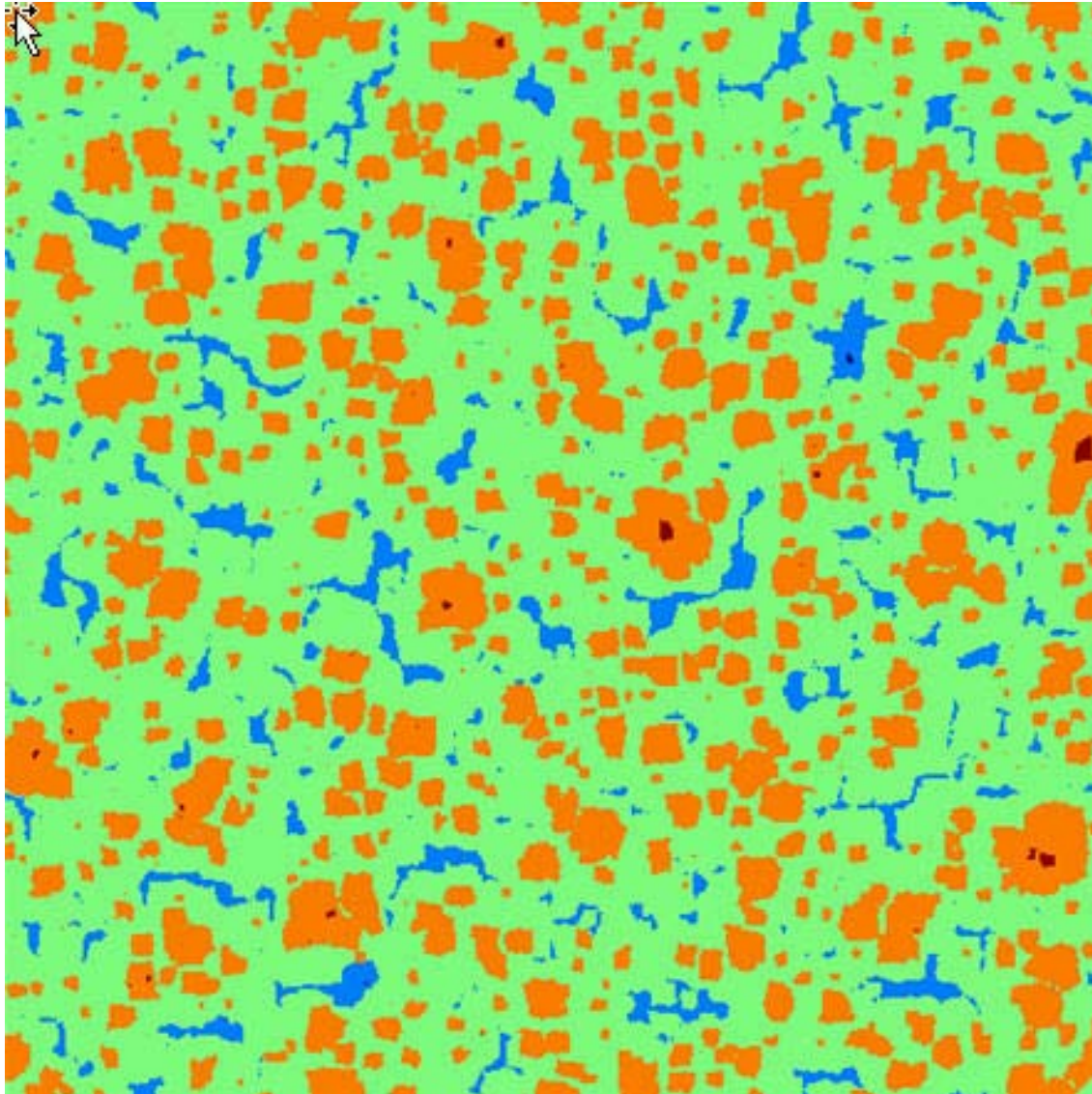
SOS Simulation for coverage=.2



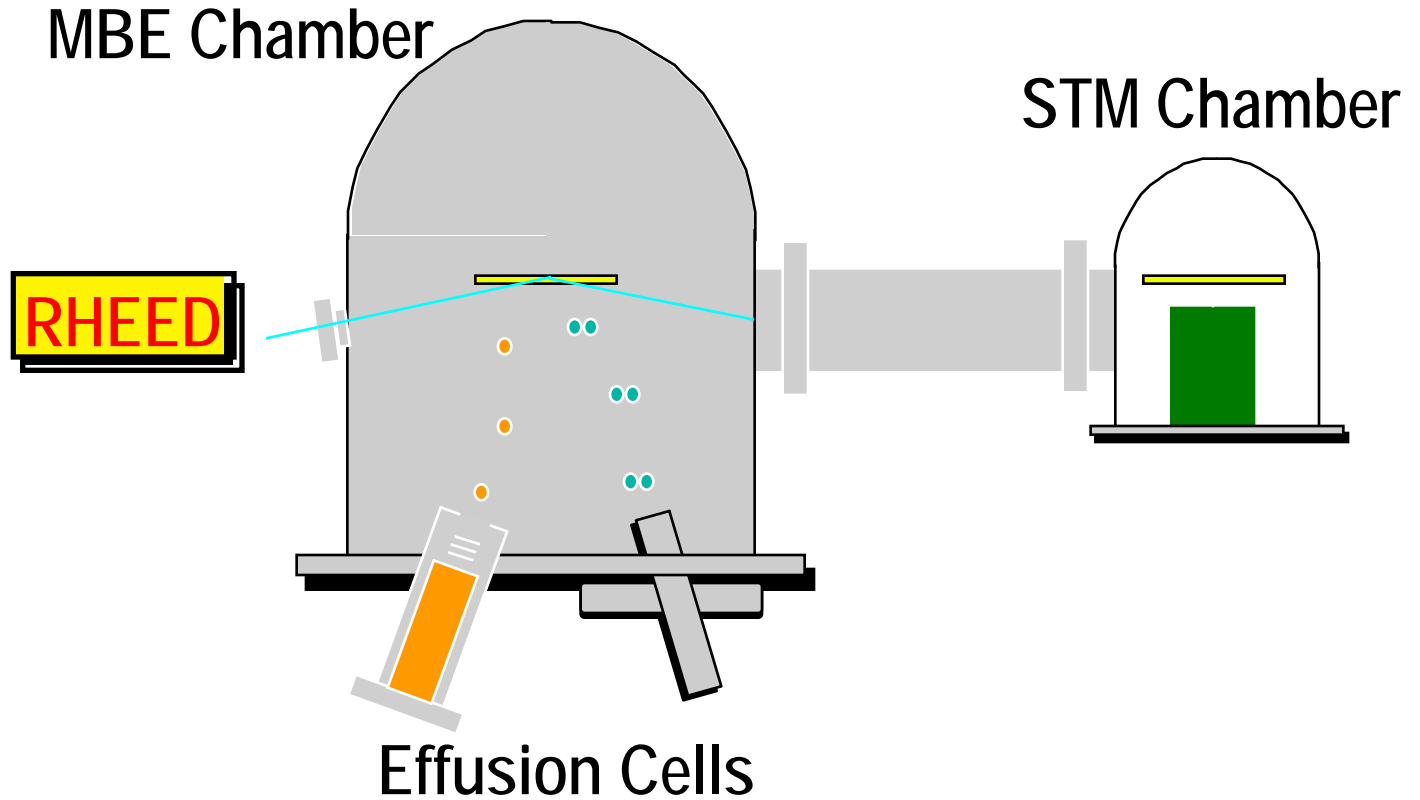
SOS Simulation for coverage=10.2



SOS Simulation for coverage=30.2



# Molecular Beam Epitaxy (MBE) Growth and Analysis Facility



# Validation of SOS Model: Comparison of Experiment and KMC Simulation (Vvedensky & Smilauer)

$E_s - E_v$  model

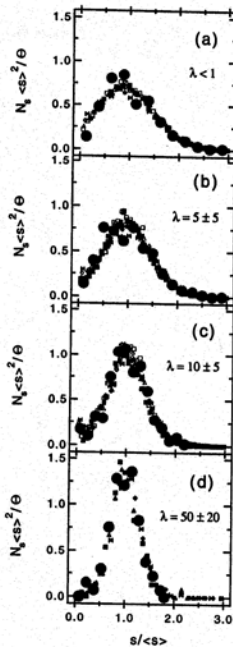
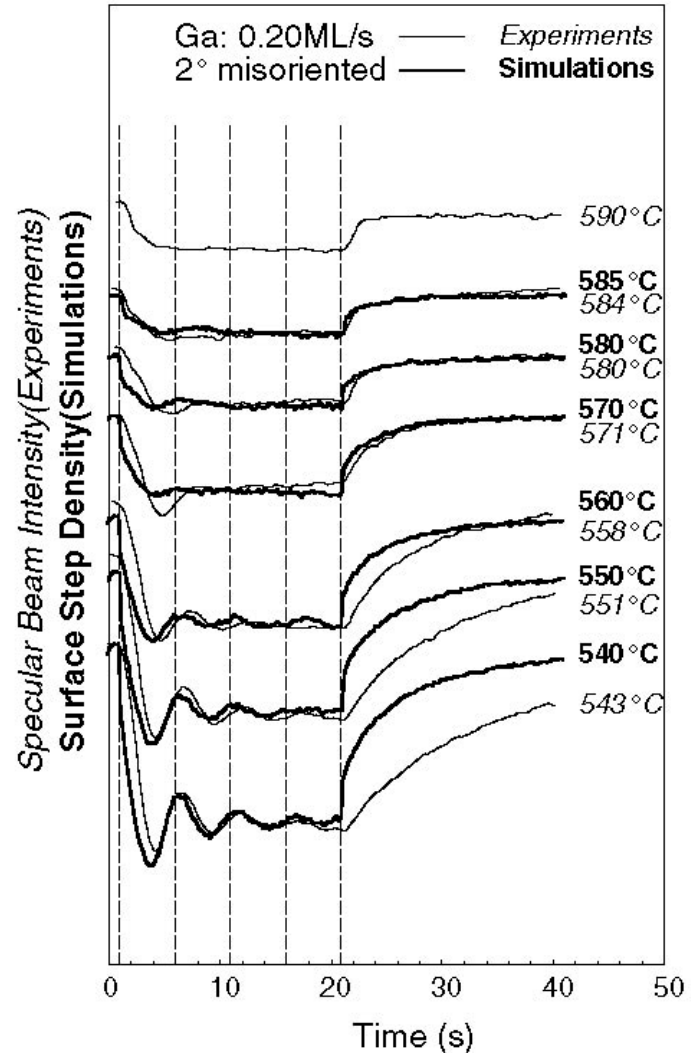


Fig. 4. Island size distributions for Fe/Fe(001) from Ref. [20] (large circles) compared to pair-bond model simulation results: (a) experiment at  $T = 20^\circ\text{C}$ , simulation for  $0.10 \leq \theta \leq 0.25$  with  $E_N = 1.0$  eV and  $F = 0.1, s^{-1}$  (open symbols) and  $E_N = 0.3$  eV and  $F = 0.5 s^{-1}$  (closed symbols); (b) experiment at  $T = 163^\circ\text{C}$ , simulation for  $0.10 \leq \theta \leq 0.25$  with  $E_N = 0.7$  eV and  $F = 0.001 s^{-1}$  (open symbols) and  $E_N = 0.3$  eV and  $F = 0.2 s^{-1}$  (closed symbols); (c) experiment at  $T = 250^\circ\text{C}$ , simulation for  $0.12 \leq \theta \leq 0.25$  with  $E_N = 0.6$  eV and  $F = 0.001 s^{-1}$  (open symbols) and  $E_N = 0.3$  eV and  $F = 0.03 s^{-1}$  (closed symbols); (d) experiment at  $T = 356^\circ\text{C}$ , simulation for  $0.12 \leq \theta \leq 0.25$  with  $E_N = 0.3$  eV and  $F = 0.001 s^{-1}$ .

Vvedensky et al.

**Island size density**

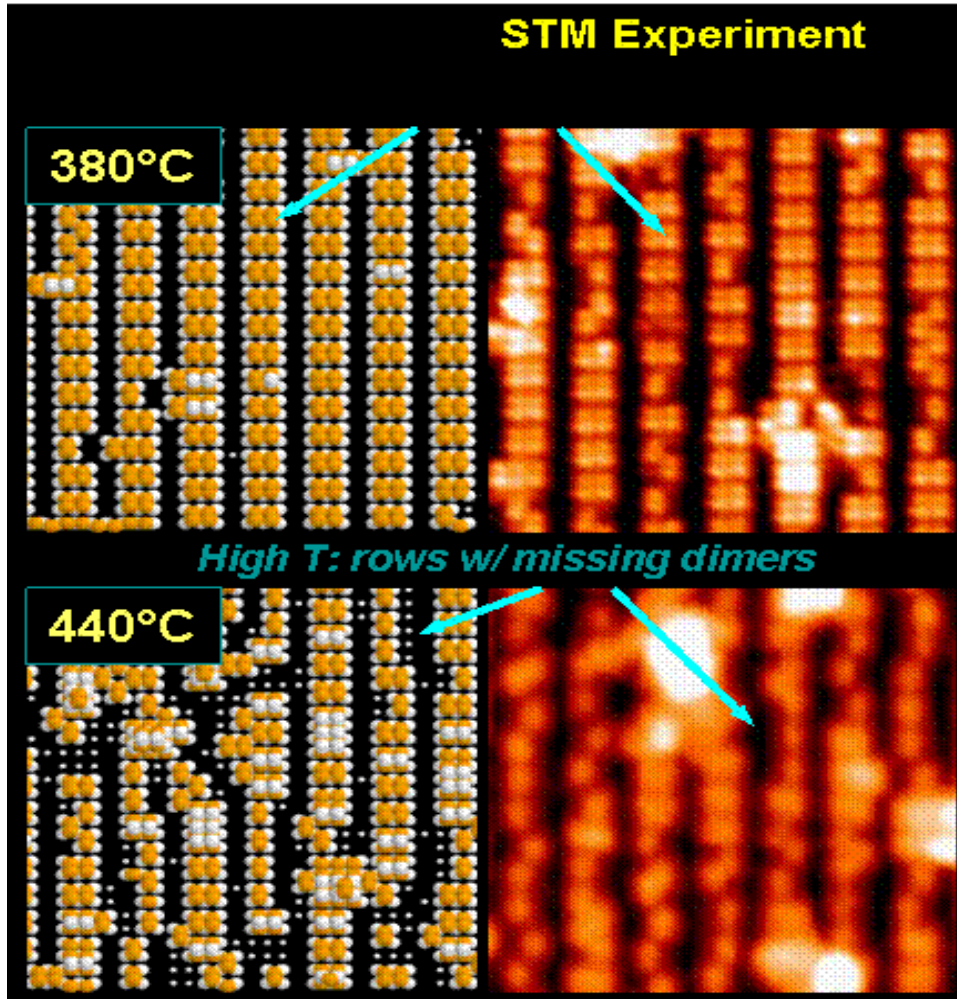


**Step Edge Density (RHEED)**

# Difficulties with SOS/KMC

- Difficult to analyze
- Computationally slow
  - adatom hopping rate must be resolved
  - difficult to include additional physics, e.g. strain
- Rates are empirical
  - idealized geometry of cubic SOS
  - cf. “high resolution” KMC

# High Resolution KMC Simulations



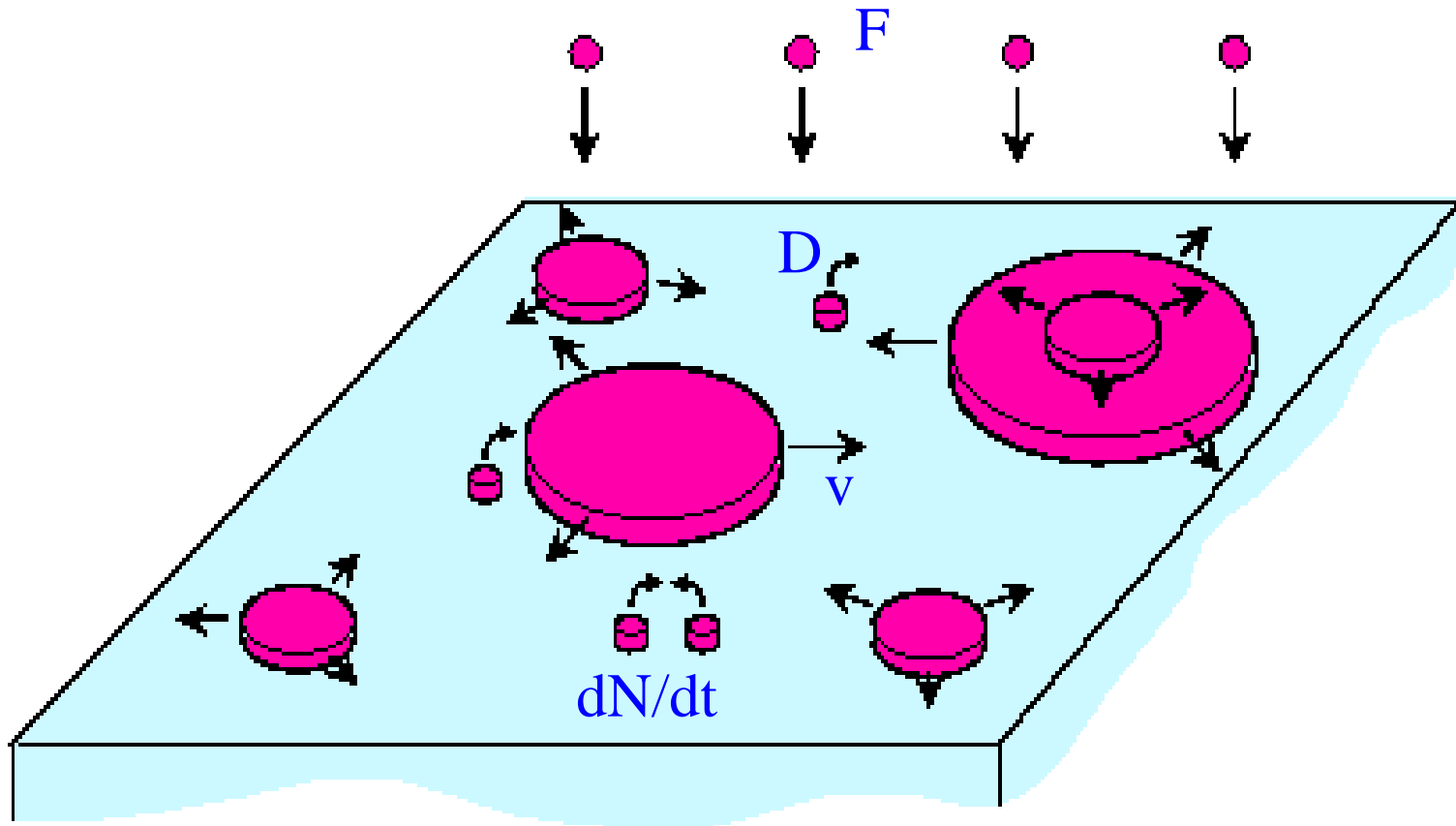
- InAs
- zinc-blende lattice, dimers
- rates from ab initio computations
- computationally intensive
  - many processes
- describes dynamical info (cf. STM)
- similar work
  - Vvedensky (Imperial)
  - Kratzer (FHI)

High resolution KMC (left); STM images (right)  
Gyure, Barvosa-Carter (HRL), Grosse (UCLA,HRL)  
Sapporo 2010

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# Island Dynamics



# Island Dynamics

- BCF Theory: Burton, Cabrera, Frank (1951)
- Epitaxial surface
  - adatom density  $\rho(x,t)$
  - Step edges = union of curves  $\Gamma(t)$
  - continuum in lateral direction, atomistic in growth direction

- Evolution of  $\rho$  and  $\Gamma$

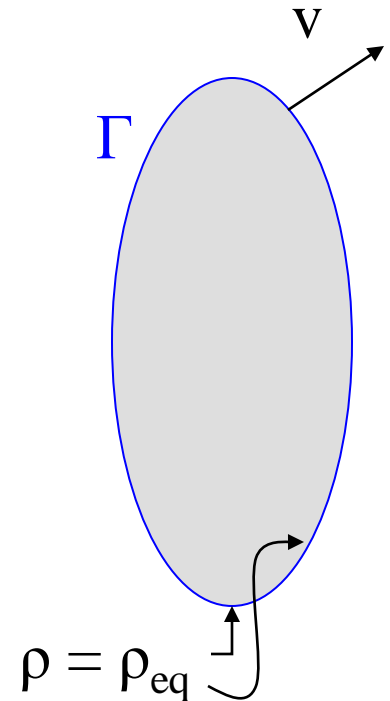
- Adatom diffusion equation with equilibrium BC

$$\rho_t = D \Delta \rho + F$$

$$\rho = \rho_{\text{eq}} \quad \text{on } \Gamma(t)$$

- $F$  = deposition rate,  $D$  = diffusion coefficient
- Step edge velocity:  $\Gamma(t)$  moves at normal velocity

$$v = D \left[ \partial \rho / \partial n \right]$$



## **Additions to BCF Theory**

- Nucleation and breakup of islands
- Step stiffness/line tension
- Strain effects (Lecture 2)
- Numerical implementation: Level set method

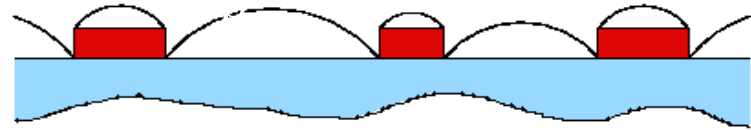
# Nucleation (and Breakup)

- Islands nucleate due to collisions between adatoms
  - Rate =  $D \sigma_1 \rho^2$
  - $\sigma_1$  = capture number for nucleation
    - accounts for correlation between random walkers: they have not collided earlier
- Modification in  $\rho$  eqtn
  - Nucleation is a loss term
 
$$\rho_t = D\Delta\rho + F - dN/dt$$

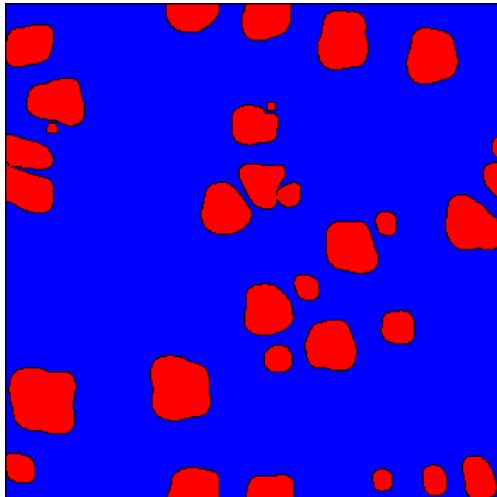
$$dN/dt = \int D \sigma_1 \rho^2 dx$$
- Choice of nucleation time and position
  - Deterministic time, stochastic position
  - When  $N$  crosses an integer, nucleate a new island
    - $N(t) \approx \#$  islands at time  $t$
  - Choose position at random with probability density proportional to
 
$$D \sigma_1 \rho^2$$
  - Alternatives to this choice of position were not successful
  - Ratsch et al. (2000)
- Similar method for adatom detachment and breakup of small islands

# Nucleation: Deterministic Time, Random Position

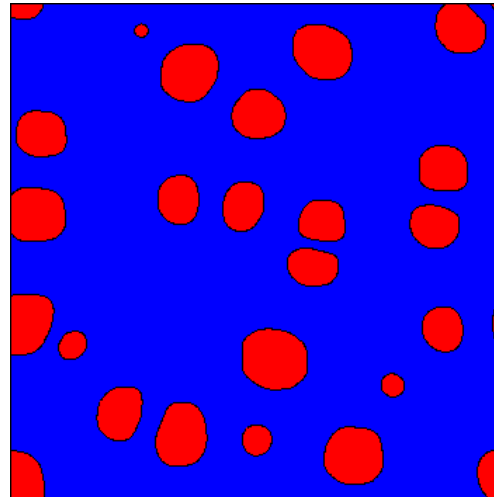
$$\frac{dN}{dt} = D \langle \rho(\mathbf{x}, t)^2 \rangle$$



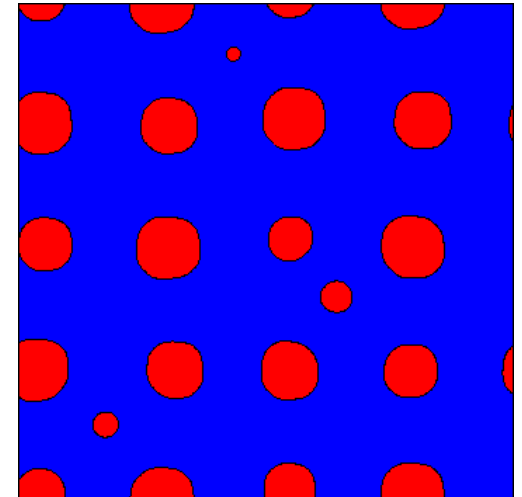
**Random Seeding**  
independent of  $\rho$



**Probabilistic Seeding**  
weight by local  $\rho^2$

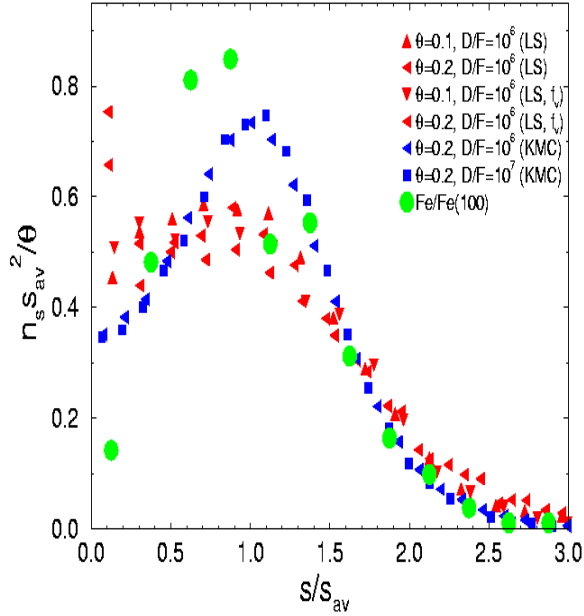


**Deterministic Seeding**  
seed at maximum  $\rho^2$

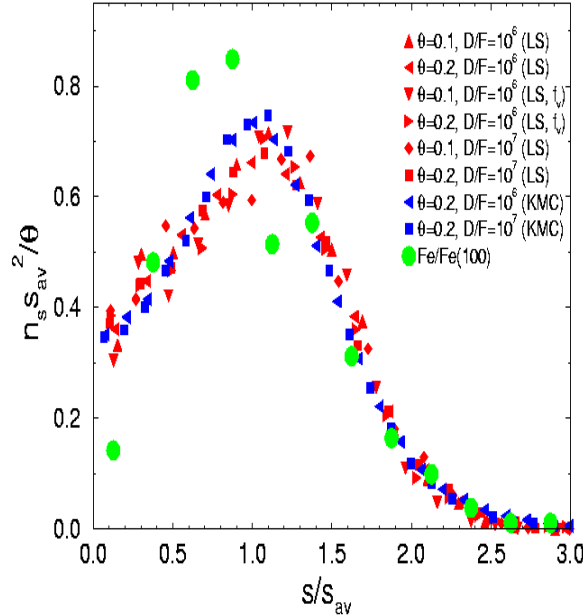


# Effect of Seeding Style on Scaled Island Size Distribution

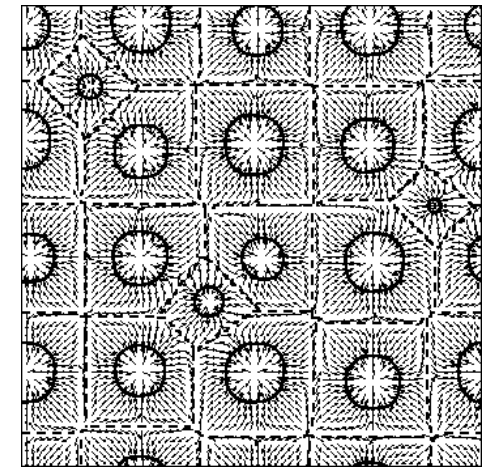
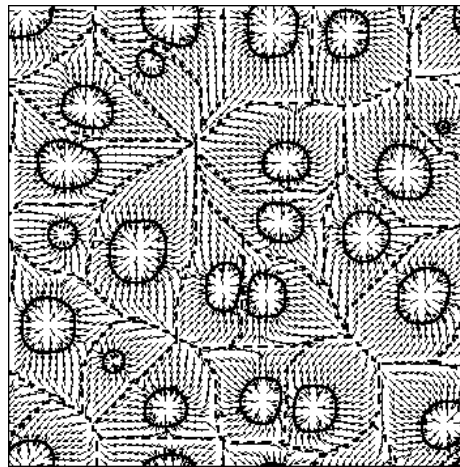
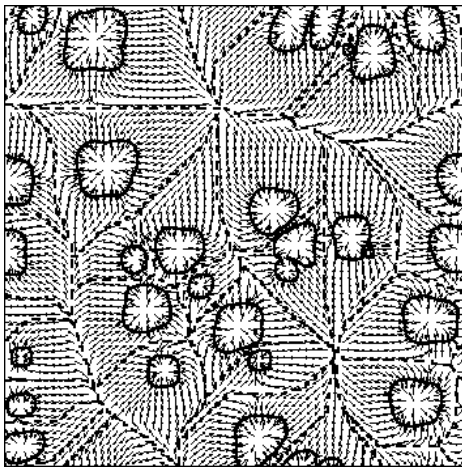
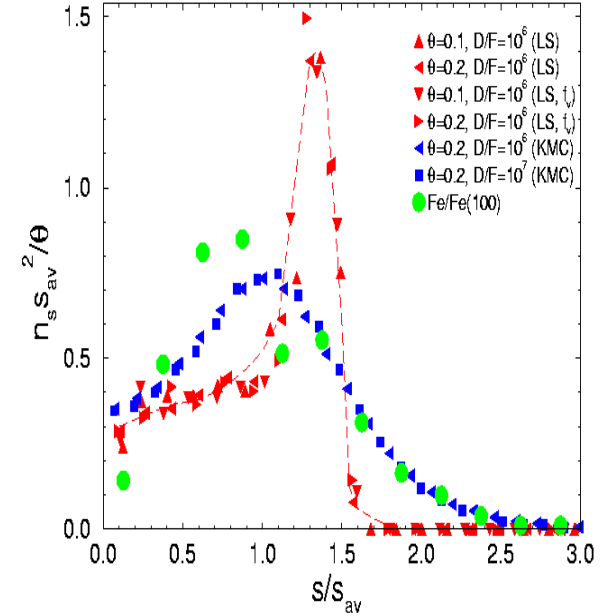
Random Seeding



Probabilistic Seeding



Deterministic Seeding



# Line Tension/Step Stiffness

- Gibbs-Thomson terms: boundary condition for  $\rho$  and island velocity  $v$

$$D \partial \rho / \partial n = D(\rho - \rho_*) - \tilde{\mu} \kappa$$

$$v = D [\partial \rho / \partial n] - \tilde{\mu} \kappa_{ss}$$

- Line tension  $\gamma$  and step stiffness  $\tilde{\gamma}$  satisfy

$$\tilde{\gamma} = (T / D \rho_*) \tilde{\mu} \quad = \text{free energy per unit length}$$

$$\tilde{\gamma} = \gamma + \gamma_{ss}$$

- Asymptotic analysis of detailed step edge model for  $|\kappa| < O(P_{\text{edge}}) \ll 1$ 
  - First derivation of Gibbs-Thomson from kinetics rather than energetics
    - Previous derivations use equilibrium or thermodynamic driving forces
  - $\rho_*$  from kinetic steady state RC & Li (2003)
  - Anisotropy of  $\tilde{\gamma}$  RC & Margetis (2007)



# Anisotropy of step stiffness $\tilde{\gamma}$

$$\tilde{\gamma} = \begin{cases} c \theta^{-1} & \text{for } P_E^{1/2} \ll \theta \ll 1 \\ O(1) & \text{for } 0 < \theta \ll P_E^{1/2} \end{cases}$$

$$c = \bar{c} (f_+ + f_-)_\theta$$

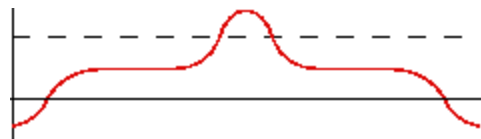
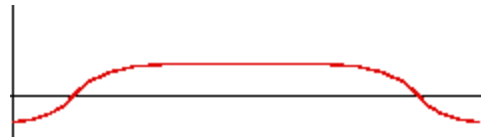
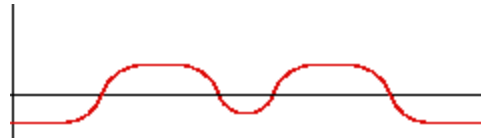
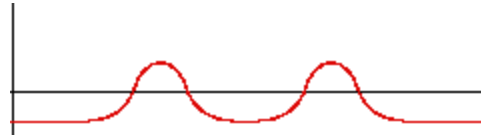
- $\theta$  = angle of step edge
- $f_+$ ,  $f_-$  are flux from upper, lower terrace
- $\theta^{-1}$  similar to results for Ising model, near-equilibrium by Einstein and Stasevich (2005)

# Level Set Method

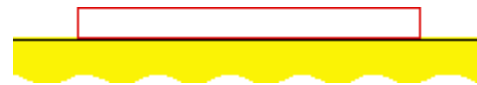
- Level set equation for description and motion of 
  - $\text{island}_n(t)$  = boundary for islands of height  $n = \{ x : \varphi(x,t) = n \}$
  - $\varphi_t + v |\text{grad } \varphi| = 0$
  - $v$  = normal velocity of 
  - Nucleation of new islands performed by “manual” raising of level set function. Requires minimal size (4 atoms) for new islands
- Implementation
  - REC, Gyure, Merriman, Ratsch, Osher, Zinck (1999)
  - Chopp (2000)
  - Smereka (2000)
- Choice of grid
  - Numerical grid needed for diffusion and LS equations
  - Physical (atomistic) grid needed for nucleation and breakup
  - We use a single atomistic grid, which we consider to be a numerical grid when needed

## The Levelset Method

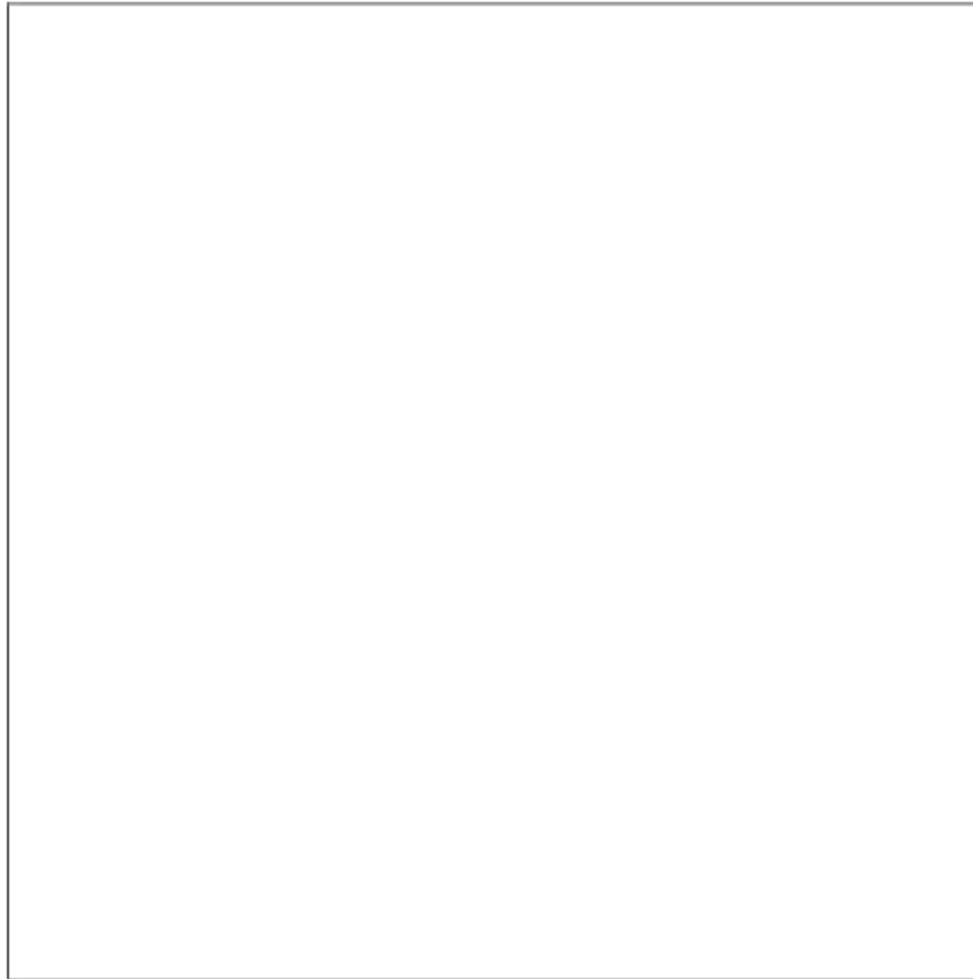
Level Set Function  $\phi$



Surface Morphology

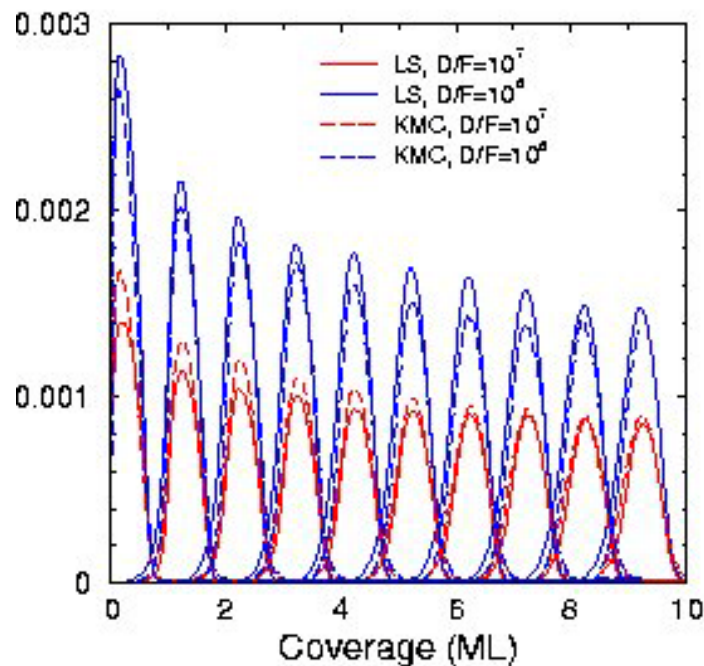


# **Simulated Growth by the Island Dynamics/Level Set Method**

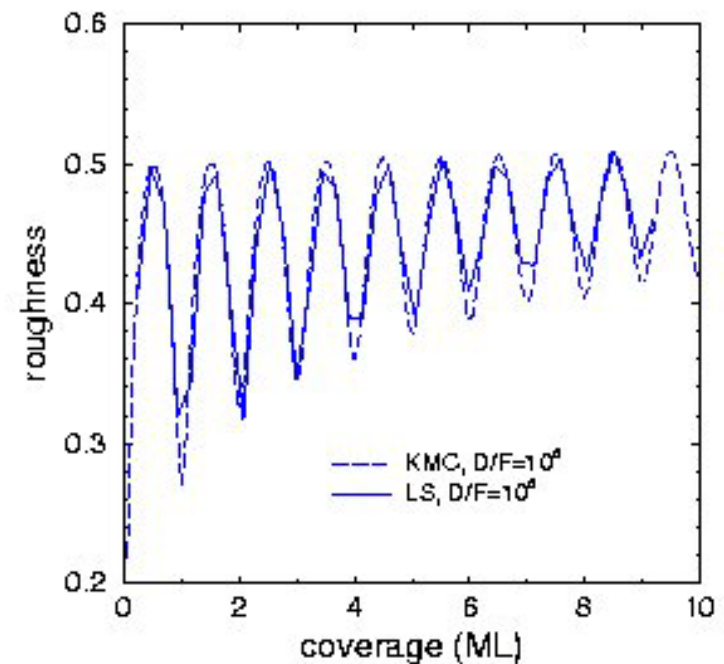


## Multilayer Comparison Levelset - KMC

Island Densities



Surface Roughness



We choose edge diffusion in KMC as  $D_{\text{edge}}/D = 0.01$ .

LS = level set implementation of island dynamics

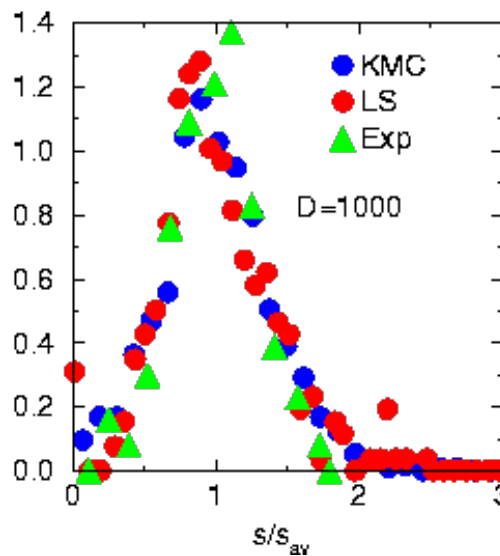
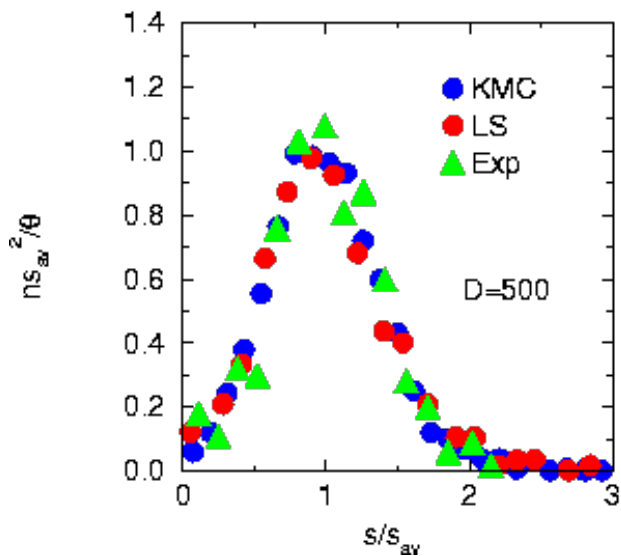
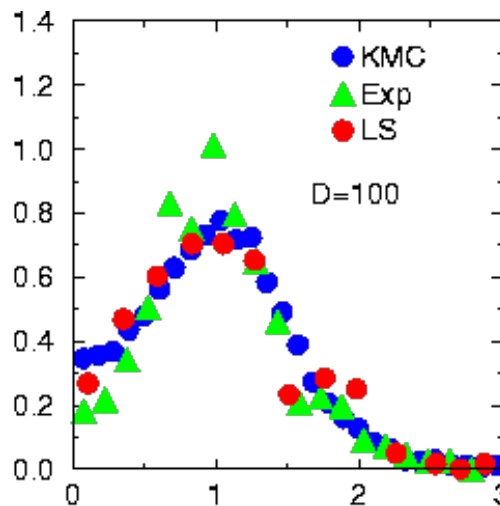
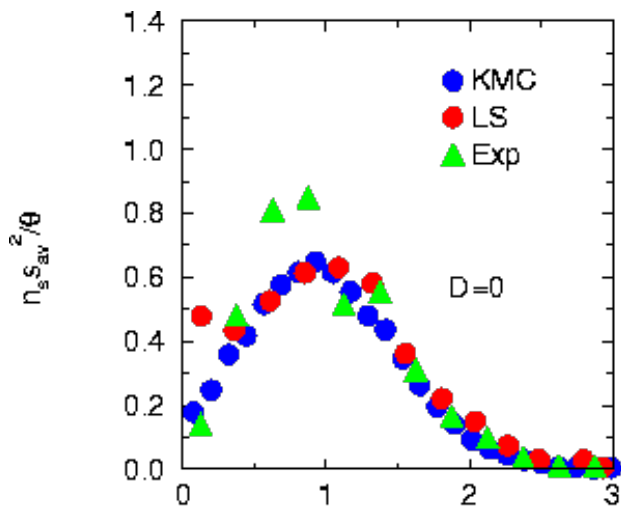
# Island size distributions

Experimental Data for Fe/Fe(001), Stroscio and Pierce, Phys. Rev. B 49 (1994)

D = detachment rate

Stochastic nucleation and breakup of islands

Petersen, Ratsch, REC, Zangwill (2001)



# Computational Speed: Level Set vs. KMC

- LS  $\approx$  KMC for nucleation dominated growth
  - Diffusion computation on atomistic lattice is slow
- LS  $\gg$  KMC for attachment/detachment dominated
  - Frequent attachment/detachment events represented by single effective detachment

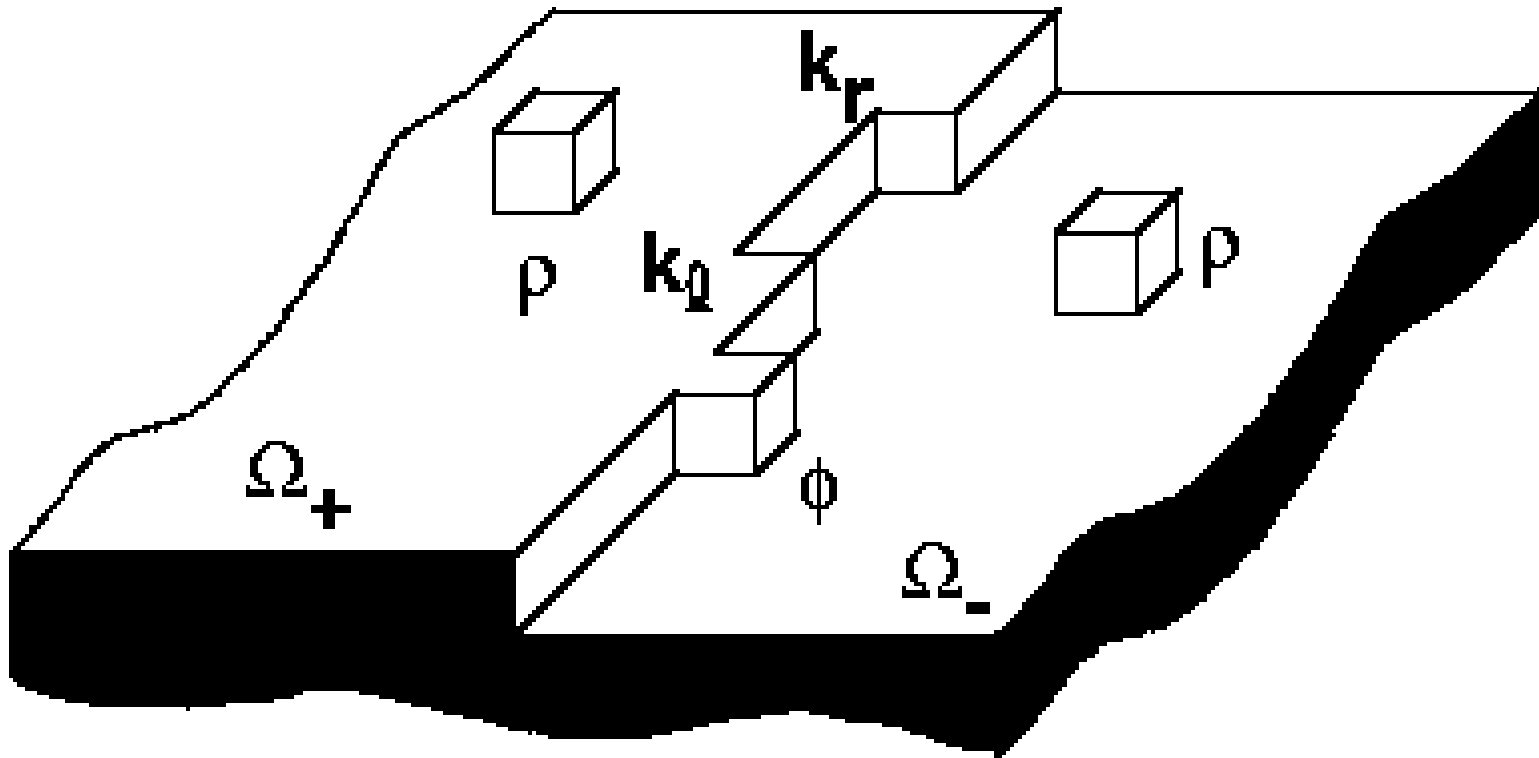
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# Kinetic Theory for Step Edge Dynamics

- Theory for structure and evolution of a step edge
  - Mean-field assumption for edge atoms and kinks
  - Dynamics of corners are neglected
- Equilibrium solution (BCF)
  - Gibbs distribution  $e^{-E/kT}$  for kinks and edge atoms
  - Detailed balance at edge between each process and the reverse process
- Kinetic steady state
  - Based on balance between unrelated processes
- Applications of detailed model
  - Estimate of roughness of step edge, which contributes to detachment rate
  - Starting point for kinetic derivation of Gibbs-Thomson
- References
  - REC, E, Gyure, Merriman & Ratsch (1999)
  - Similar model by Balykov & Voigt (2006), Filimonov & Hervieu (2004)
  - Related models by Evans & collaborators

# Step Edge Model



- adatom density  $\rho$
- edge atom density  $\phi$
- kink density (left, right)  $k$
- terraces (upper and lower) ▶

- Evolution equations for  $\phi$ ,  $\rho$ ,  $k$

$$\partial_t \rho - D_T \Delta \rho = F \quad \text{on terrace}$$

$$\partial_t \phi - D_E \partial_s^2 \phi = f_+ + f_- - f_0 \quad \text{on edge}$$

$$\partial_t k - \partial_s (w (k_r - k_\ell)) = 2 (g - h) \quad \text{on edge}$$

# Equilibrium from Detailed Balance

edge atom  $\leftrightarrow$  terrace adatom:

$$D_E \varphi = D_T \rho$$

kink  $\leftrightarrow$  edge atom:

$$D_K k = D_E k \varphi$$

kink pair (“island”)

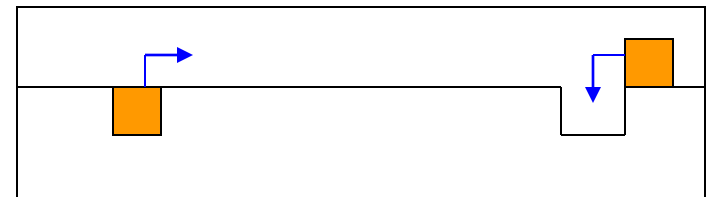
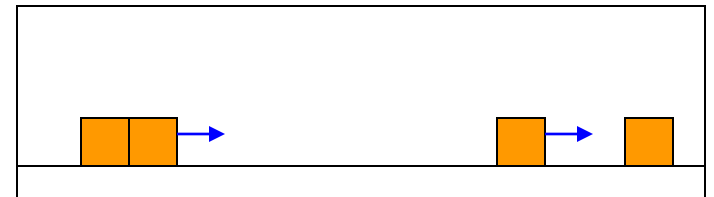
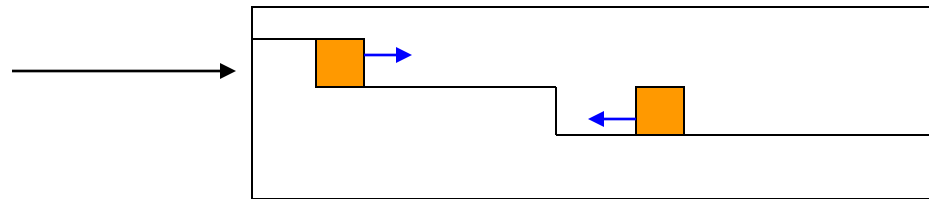
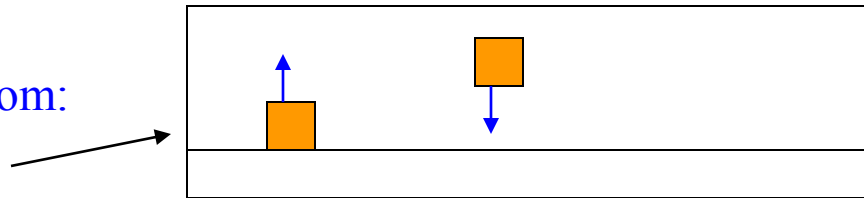
$\leftrightarrow$  edge atom pair:

$$D_K (1/4) k^2 = D_E \varphi^2$$

kink pair (“hole”) + edge atom

$\leftrightarrow$  straight step:

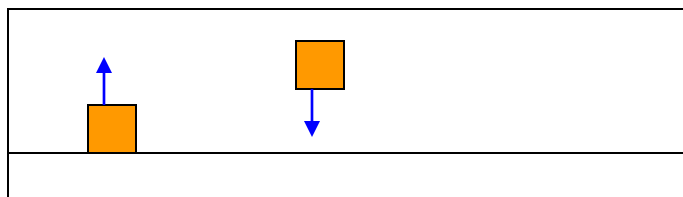
$$D_S = D_E (1/4) k^2 \varphi$$



*Steady*  
*state*  
~~Equilibrium~~ from ~~Detailed~~ Balance

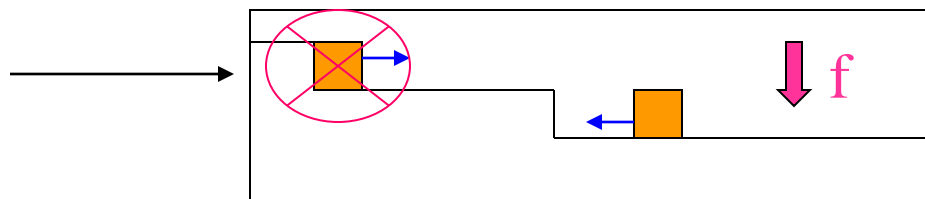
edge atom  $\leftrightarrow$  terrace adatom:

$$D_E \phi = D_T \rho$$



kink  $\leftrightarrow$  edge atom:

~~$$D_K k = D_E k \phi$$~~



kink pair ("island")

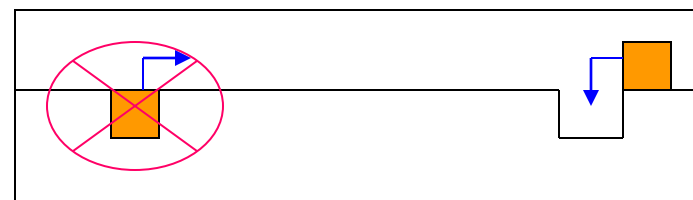
$\leftrightarrow$  edge atom pair:

~~$$f = D_K (1/4) k^2 = D_E \phi^2$$~~

kink pair ("hole") + edge atom

$\leftrightarrow$  straight step:

~~$$D_S = D_E (1/4) k^2 \phi$$~~



$f =$  net flux to step edge

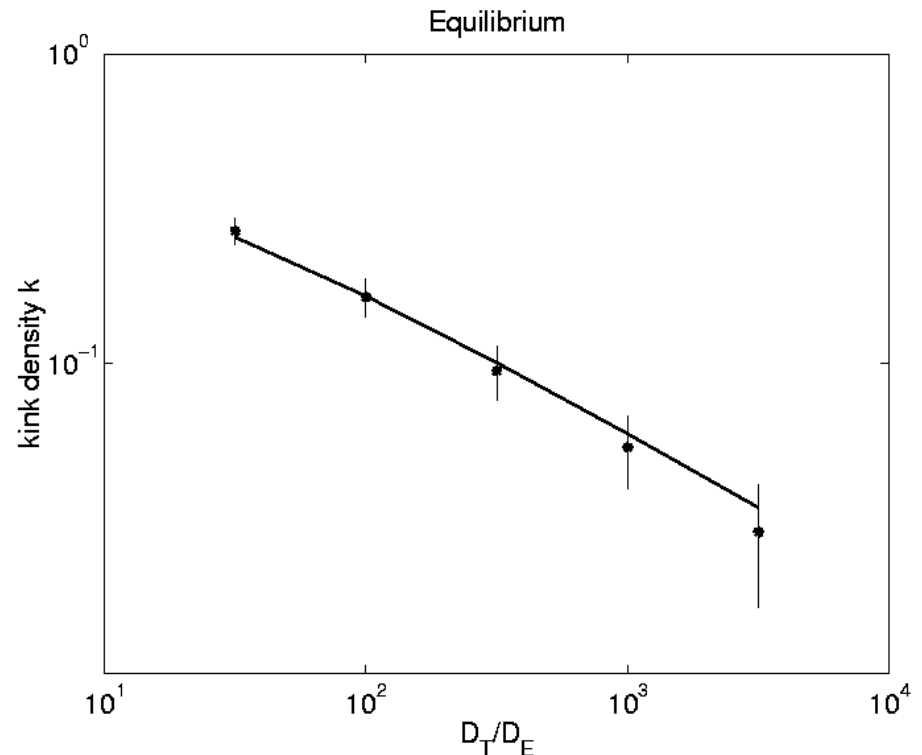
# Equilibrium Solution

$$\rho = (D_E/D_T)\varphi$$

$$\varphi = k^2/4$$

$$k = 2\sqrt{D_K/D_E}$$

- Solution for  $F=0$  (no growth)
- Derived from detailed balance
- $D_T$ ,  $D_E$ ,  $D_K$  are diffusion coefficients (hopping rates) on Terrace, Edge, Kink in SOS model



Comparison of results from theory(-)  
and KMC/SOS (●)

# Kinetic Steady State vs. Equilibrium

## Kinetic steady state

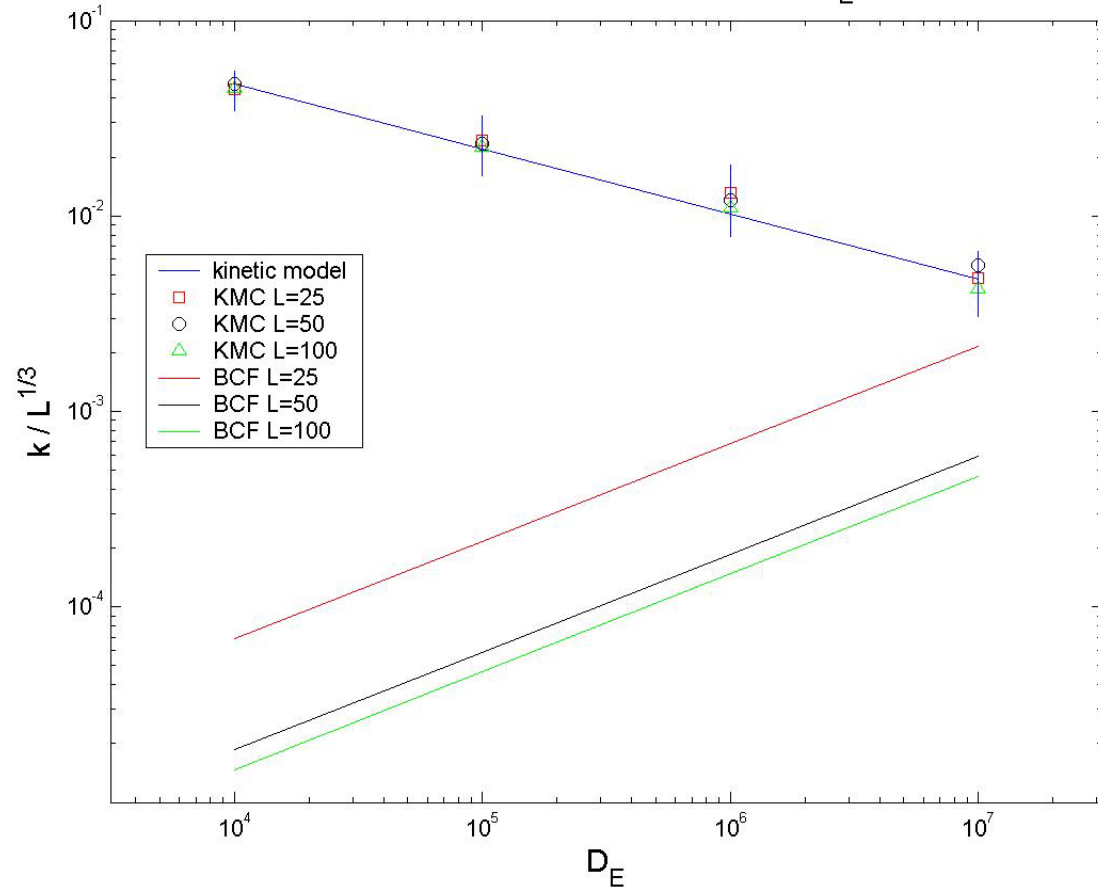
$$\rho_{\pm} = (D_E/D_T)\varphi$$

$$\varphi = k^2/4$$

$$k = \left(\frac{16}{15}P_{\text{edge}}\right)^{1/3}$$

- Solution for  $F > 0$
- Derived from kinetic balance, not detailed balance
- $k \gg k_{\text{eq}}$
- $P_{\text{edge}} = f/D_E$  “edge Peclet #”

Kink Density  $k$  vs. Edge Diffusion  $D_E$



Comparison of scaled results from steady state (-), BCF(- - -), and KMC/SOS (●□△) for  $L=25,50,100$ , with  $F=1, D_T=10^{12}$

# Hybrid and Accelerated Methods: Island Dynamics and KMC

- Schulze, Smereka, E (2003)
- Russo, Sander, Smereka (2004)
- Schulze (2004)
- DeVita, Sander, Smereka (2006)
- Sun, Engquist, REC, Ratsch (2007)

# Outline

- Epitaxial Growth
  - molecular beam epitaxy (MBE)
  - Step edges and islands
- Solid-on-Solid using kinetic Monte Carlo
  - Atomistic, stochastic
- Island dynamics model
  - Continuum in lateral directions/atomistic in growth direction
  - Level set implementation
  - Kinetic step edge model
- Conclusions

# Summary

- Island dynamics method for epitaxial growth
  - Coarse-graining of KMC
  - Stochastic nucleation
- Kinetic model for step edge
  - kinetic steady state  $\neq$  BCF equilibrium
  - validated by comparison to SOS/KMC
- Next lectures
  - Inclusion of strain in epitaxial systems
  - Strain leads to geometric structure (e.g. quantum dots) and alloy segregation